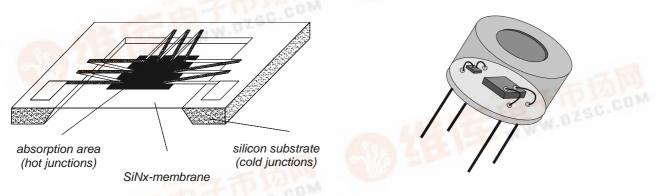
捷多邦,专业PCB打样<u>工厂</u>,24小时加急出货 <u>Thermose</u>nsors TS105-1 / TS105-2

THERMOPILES are used for non-contact surface temperature measuring.

Any object emits infrared radiation. The radiation power is increasing with growing surface temperatures. Based on this relation, THERMOPILES measure the emitted power and determine the object's temperature precisely.

Function Principle

THERMOPILES are based on the Seebeck effect, which is used since a long time for conventional thermocouples. The application of micromechanics and thin film technology allows the production of miniaturized and cost effective sensor elements.



A multitude of thermojunctions deposited on a silicon substrate is connected in series to form a THERMOPILE. The hot junctions are thermally insulated from the cold junctions on the substrate by etching a self-supporting extremly thin membrane. An absorbing layer on the hot junctions transforms the incoming radiation into heat. A voltage proportional to the radiation is generated by the thermoelectric effect. The sensors are delivered in TO5-packages. Different housings and filter types can be selected to find an optimal solution for each application. Chips without housing are available as well.

Filter

Technical Data

Parameter	Symbol	Unit	Value	Condition	100T	
Number of thermojunctions	n		100		90-	
Material			BiSb, NiCr		90	
Active Area	A _A	mm²	0.7 * 0,7		80 08	
Chip Size	Ac	mm²	2.0 * 2.0		~70+ ~ ~~~	4
Resistance of Thermopiles	R	kΩ	50 ± 15	25 °C		~
TC of resistance	TCR	%/K	-0.03 ± 0.02	+25+75 °C	500	
Sensitivity of sensor	Sc	V/W	typical 110	25°C, 500 K, DC		
TC of sensitivity	TCS	%/K	-0.52 ± 0.08	+25+75 °C	En IV	
Specific detectivity	D*	cm*Hz ^{1/2} / W	2.1 * 10 ⁸	500 K, DC	E B	
Noise equivalent power	NEP	nW	0.35	500 K, 1 Hz	F-30+ V	
Noise voltage	U_N	nV / Hz ^{1/2}	37	500 K, 1 Hz	20-	
Time constant	t63	ms	40 ± 10	500 K, 1 Hz	10	
Operation temperature	Т	°C	-20 100		10+	
Storage temperature	T	°C	-40 100		0+-++++++++++++++++++++++++++++++++++++	
Reference Resistor					4 5 6 7 8 9 10 11 12 1 Wávelength (um)	3 1
Resistance	R _{Ni}	Ω	1000 ± 0.4%	0 °C		
TC of resistance	TCR _{Ni}	ppm / K	6178 ±1%	0 °C100 °C		
Function: $R(T) = 1000Q + 6.17$	*T*Q for detaille	ed information se	e data sheet of	reference resistor		

 $1000\Omega + 6,17^{*}T^{*}\Omega$, for detailled information see data sheet of reference resistor



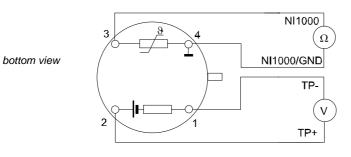
Sensors in thin film technology

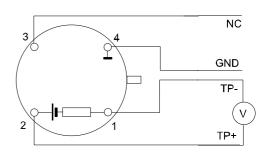
HL-Planartechnik GmbH Hauert 13 44 227 Dortmund Tel.: ++49 / (0)231 / 97400 Fax.: ++49 / (0)231 / 974020

Thermosensors TS105-1 / TS105-2

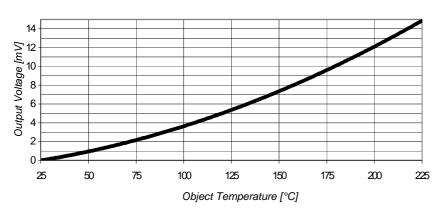
Connecting Diagramm TS105-1

TS105-2





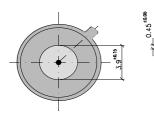
Output Voltage versus Objekt Temperature

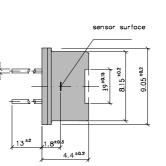


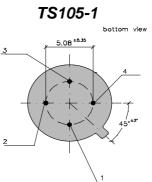
Conditions: Distance Thermopile/Black Body 5 cm, emissivity= 1, surrounding temperature 25°C

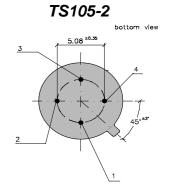
Tables with emissivity of different materials and surfaces are available.











Applications

- contactless measurement of surface temperatures or IR-Radiation
- temperature measurement at moving objects
- continous temperature control in manufacturing processes
- thermal alarm systems
- further applications in safety-, consumer-, environmental technics and automotive systems
- absorbing measurement for gas analysis (see special data sheet)
- climate control systems
- medical instruments

Further products with different filters and packages are available, see separate data sheets

Technical data are subject to change without notice

Sensors in thin film technology

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